## Rudra Sankar Dhar

List of Publications by Year in descending order

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| #  | Article   | IF  | CITATIONS |
|----|---|-----|-----------|
| 1  | Physics & Modeling of Ambipolar Snapback Behavior in Gate Grounded NMOS. Silicon, 2022, 14, 3221-3231.  | 3.3 | 2         |
| 2  | Exploration and development of tri-gate quantum well barrier FinFET with strained nanosystem channel for enhanced performance. Computers and Electrical Engineering, 2022, 98, 107687.                  | 4.8 | 5         |
| 3  | Efficient Optimization Technique for Analysing the Performance of Bifacial Solar Cells Using Fuzzy<br>Logic. Lecture Notes in Networks and Systems, 2022, , 263-272.                                    | 0.7 | 2         |
| 4  | Utility of a Reverse Double-drift Structure for Fabricating GaN IMPATT Diode Operating in the Terahertz Regime. Journal of Nano- and Electronic Physics, 2021, 13, 03014-1-03014-4.                     | 0.5 | 0         |
| 5  | Neuro-feedback system for real-time BCI decision prediction. Microsystem Technologies, 2021, 27, 3725-3734.   | 2.0 | 4         |
| 6  | Estimation and analysis for modelling of stand-alone graphene/AlGaAs/GaAs schottky solar<br>photovoltaic cell module for power conversion efficiency. Microsystem Technologies, 2021, 27,<br>3693-3701. | 2.0 | 3         |
| 7  | Analysis of mechanical stress and structural deformation on a solar photovoltaic panel through various wind loads. Microsystem Technologies, 2021, 27, 3465-3474.                                       | 2.0 | 5         |
| 8  | Performance Estimation and Analysis of 3D Trigate HOI FinFET Using Strained Channel for Reduced<br>Area. Lecture Notes in Electrical Engineering, 2021, , 289-299.                                      | 0.4 | 0         |
| 9  | Performance analysis and development of strain induced quantum well based nano-system device technology. Microsystem Technologies, 2021, 27, 3703-3710.   | 2.0 | 7         |
| 10 | Performance investigations of filtering methods for T1 and T2 weighted infant brain MR images.<br>Microsystem Technologies, 2021, 27, 3711-3723.  | 2.0 | 4         |
| 11 | Development and Characterization of Nano Material Membrane Device for Enhanced Transmittance. , 2021, , .   |     | 1         |
| 12 | Comparative performance analysis based short channel effects for TG Nano FinFETs. Journal of Physics: Conference Series, 2021, 1921, 012014.  | 0.4 | 1         |
| 13 | Bio-sensing application of chalcogenide thin film in a graphene-based surface plasmon resonance (SPR) sensor. Sadhana - Academy Proceedings in Engineering Sciences, 2021, 46, 1.                       | 1.3 | 5         |
| 14 | Exploration of improved leakage based performance analysis for underlap induced strained-Si layer in<br>tri-layered channel DG nanoFETs. Physica Scripta, 2021, 96, 124006.                             | 2.5 | 4         |
| 15 | Fabrication and characterization of copper based semiconducting materials for optoelectronic applications. Microsystem Technologies, 2021, 27, 3475-3482.   | 2.0 | 2         |
| 16 | Determination of Enriched Quantum Efficiency with InGaN/GaN Multiple Quantum Well Solar Cells.<br>Micro and Nanosystems, 2021, 13, 418-425.   | 0.6 | 1         |
| 17 | Micro-features of ambipolar snapback behaviour under high current injection to design capacitorless memory device. Physica Scripta, 2021, 96, 124069.   | 2.5 | 1         |
| 18 | Significance of Different Buffer Layers in an SPR Multichannel Sensor. , 2020, , .  |     | 0         |

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|----|---|-------------------|-----------|
| 19 | TCAD Based Optimization of SJ Infrared Solar Cell for an Efficient Thermo-Photovoltaic Application. , 2020, , .   |                   | 0         |
| 20 | Design of DG MOSFET with Tri-Layered Strained Silicon Channel. Journal of Physics: Conference Series, 2020, 1478, 012002.   | 0.4               | 5         |
| 21 | Modelling and Simulation of 10nm Strained Channel DG- Nano-FET. , 2020, , .   |                   | 2         |
| 22 | Influence of Design Parameters on Multilayered Nanoplasmonic Structures in Modified<br>Kretschmann-Raether Configurations. Plasmonics, 2020, 15, 1133-1140.                               | 3.4               | 4         |
| 23 | TCAD Modeling and Analysis of sub-30nm Strained Channel MOSFET. Algorithms for Intelligent Systems, 2020, , 1383-1388.  | 0.6               | 1         |
| 24 | Analysis of Capacitance–Voltage Characteristics for Ultrathin Si/SiGe/Si Hetero-Layered MOS<br>Structure. Advances in Intelligent Systems and Computing, 2020, , 83-89.                   | 0.6               | 0         |
| 25 | Bipolar effects in snapback mechanism in advanced n-FET transistors under high current stress conditions. Journal of Physics Communications, 2020, 4, 065009.                             | 1.2               | 0         |
| 26 | TCAD Modelling of 30nm Strained-Si/SiGe/Si Channel MOSFET. , 2019, , .  |                   | 3         |
| 27 | Cell thickness optimization of dual junction InGaP/GaAs solar cell against temperature variation. , 2019, , .   |                   | 2         |
| 28 | Design of Double Gate Nano-FET. , 2019, , .   |                   | 0         |
| 29 | Strain Engineering Analysis for Nanoscaled Tri-layered Heterostructure-on-Insulator. International<br>Journal of Nanoscience, 2019, , .   | 0.7               | 2         |
| 30 | Investigation of 30nm Tri-layered Strained Silicon HOI MOSFET using TCAD. , 2018, , .   |                   | 0         |
| 31 | Two Strained-Si Layers in Channel Region of HOI MOSFET. , 2018, , .   |                   | 0         |
| 32 | Double Strained Channel MOSFET: Deep Into Sub-Microns. , 2018, , .  |                   | 0         |
| 33 | Development of Triâ€Layered sâ€Si/sâ€SiGe/sâ€Si Channel Heterostructureâ€onâ€Insulator MOSFET for Enhanc<br>Drive Current. Physica Status Solidi (B): Basic Research, 2018, 255, 1800034. | ed <sub>1.5</sub> | 19        |
| 34 | Development of double strained Si channel for heterostructure on insulator MOSFET. , 2017, , .  |                   | 2         |
| 35 | Development of double strained Si channel for heterostructure on insulator MOSFET., 2017, , .   |                   | 7         |
| 36 | Double strained Si channel heterostructure on insulator MOSFET in sub-100nm regime. , 2017, , .   |                   | 6         |

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|----|--|-----|-----------|
| 37 | Nanoscopic voltage distribution of operating cascade laser devices in cryogenic temperature. Journal of Microscopy, 2016, 262, 226-231.  | 1.8 | 0         |
| 38 | Electrical scanning probe microscopy of electronic and photonic devices: connecting internal measures. Nanotechnology Reviews, 2016, 5, .  | 5.8 | 4         |
| 39 | Direct Nanoscale Imaging of Evolving Electric Field Domains in Quantum Structures. Scientific Reports, 2014, 4, 7183.  | 3.3 | 26        |
| 40 | Twoâ€dimensional profiling of carriers in terahertz quantum cascade lasers using calibrated scanning spreading resistance microscopy and scanning capacitance microscopy. Journal of Microscopy, 2013, 251, 35-44.         | 1.8 | 4         |
| 41 | Direct charge measurements to read back stored data in nonvolatile memory devices using scanning capacitance microscopy. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2013, 31, 061801. | 1.2 | 8         |
| 42 | Measuring the exciton diffusion length of C <sub>60</sub> in organic planar heterojunction solar cells. Physica Status Solidi (A) Applications and Materials Science, 2011, 208, 1967-1971.                                | 1.8 | 36        |
| 43 | Fabrication and analysis of emerging electrochromic nanomaterial membrane device for smart   | 2.2 | 0         |